

## REPETITIVE AVALANCHE AND dv/dt RATED HEXFET® TRANSISTOR

## IRHN9230 P-CHANNEL RAD HARD

### -200 Volt, 0.8Ω, RAD HARD HEXFET

International Rectifier's P-Channel RAD HARD technology HEXFETs demonstrate excellent threshold voltage stability and breakdown voltage stability at total radiation doses as high as  $10^5$  Rads (Si). Under **identical** pre- and post-radiation test conditions, International Rectifier's P-Channel RAD HARD HEXFETs retain **identical** electrical specifications up to  $1 \times 10^5$  Rads (Si) total dose. No compensation in gate drive circuitry is required. In addition these devices are also capable of surviving transient ionization pulses as high as  $1 \times 10^{12}$  Rads (Si)/Sec, and return to normal operation within a few microseconds. Single Event Effect (SEE) testing of International Rectifier P-Channel RAD HARD HEXFETs has demonstrated virtual immunity to SEE failure. Since the P-Channel RAD HARD process utilizes International Rectifier's patented HEXFET technology, the user can expect the highest quality and reliability in the industry.

P-Channel RAD HARD HEXFET transistors also feature all of the well-established advantages of MOSFETs, such as voltage control, very fast switching, ease of paralleling and temperature stability of the electrical parameters.

They are well-suited for applications such as switching power supplies, motor controls, inverters, choppers, audio amplifiers and high-energy pulse circuits in space and weapons environments.

### Product Summary

Part Number	BV <sub>DSS</sub>	R <sub>DS(on)</sub>	I <sub>D</sub>
IRHN9230	-200V	0.8Ω	-6.5A

### Features:

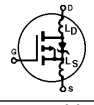
- Radiation Hardened up to  $1 \times 10^5$  Rads (Si)
- Single Event Burnout (SEB) Hardened
- Single Event Gate Rupture (SEGR) Hardened
- Gamma Dot (Flash X-Ray) Hardened
- Neutron Tolerant
- Identical Pre- and Post-Electrical Test Conditions
- Repetitive Avalanche Rating
- Dynamic dv/dt Rating
- Simple Drive Requirements
- Ease of Paralleling
- Hermetically Sealed
- Surface Mount
- Light-weight

### Absolute Maximum Ratings

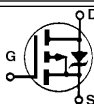
### Pre-Radiation

	Parameter	IRHN9230	Units
I <sub>D</sub> @ V <sub>GS</sub> = -12V, T <sub>C</sub> = 25°C	Continuous Drain Current	-6.5	A
I <sub>D</sub> @ V <sub>GS</sub> = -12V, T <sub>C</sub> = 100°C	Continuous Drain Current	-4.0	
I <sub>DM</sub>	Pulsed Drain Current ①	-26	
P <sub>D</sub> @ T <sub>C</sub> = 25°C	Max. Power Dissipation	75	W
	Linear Derating Factor	0.6	W/K ⑤
V <sub>GS</sub>	Gate-to-Source Voltage	±20	V
EAS	Single Pulse Avalanche Energy ②	150	mJ
I <sub>AR</sub>	Avalanche Current ①	-6.5	A
EAR	Repetitive Avalanche Energy ①	7.5	mJ
dv/dt	Peak Diode Recovery dv/dt ③	-5.0	V/ns
T <sub>J</sub>	Operating Junction	-55 to 150	°C
T <sub>STG</sub>	Storage Temperature Range		
	Package Mounting Surface Temperature	300 (for 5 seconds)	
	Weight	2.6 (typical)	

Electrical Characteristics @ T<sub>j</sub> = 25°C (Unless Otherwise Specified)

	Parameter	Min.	Typ.	Max.	Units	Test Conditions
BV <sub>DSS</sub>	Drain-to-Source Breakdown Voltage	-200	—	—	V	V <sub>GS</sub> = 0V, I <sub>D</sub> = -1.0 mA
ΔBV <sub>DSS</sub> /ΔT <sub>J</sub>	Temperature Coefficient of Breakdown Voltage	—	-0.22	—	V/°C	Reference to 25°C, I <sub>D</sub> = -1.0 mA
RDS(on)	Static Drain-to-Source	—	—	0.8	Ω	V <sub>GS</sub> = -12V, I <sub>D</sub> = -4.0A V <sub>GS</sub> = -12V, I <sub>D</sub> = -6.5A ④
	On-State Resistance	—	—	0.92		
VGS(th)	Gate Threshold Voltage	-2.0	—	-4.0	V	V <sub>DS</sub> = V <sub>GS</sub> , I <sub>D</sub> = -1.0 mA
g <sub>fs</sub>	Forward Transconductance	2.5	—	—	S (r)	V <sub>DS</sub> > -15V, I <sub>DS</sub> = -4.0A ④
IDSS	Zero Gate Voltage Drain Current	—	—	-25	μA	V <sub>DS</sub> = 0.8 x Max. Rating, V <sub>GS</sub> = 0V V <sub>DS</sub> = 0.8 x Max. Rating V <sub>GS</sub> = 0V, T <sub>J</sub> = 125°C
		—	—	-250		
IGSS	Gate-to-Source Leakage Forward	—	—	-100	nA	V <sub>GS</sub> = -20V
IGSS	Gate-to-Source Leakage Reverse	—	—	100	nA	V <sub>GS</sub> = 20V
Q <sub>g</sub>	Total Gate Charge	—	—	45	nC	V <sub>GS</sub> = -12V, I <sub>D</sub> = -6.5A V <sub>DS</sub> = Max. Rating x 0.5
Q <sub>gs</sub>	Gate-to-Source Charge	—	—	10		
Q <sub>gd</sub>	Gate-to-Drain ("Miller") Charge	—	—	25		
t <sub>d(on)</sub>	Turn-On Delay Time	—	—	50	ns	V <sub>DD</sub> = 100V, I <sub>D</sub> = -6.5A, R <sub>G</sub> = 7.5Ω
t <sub>r</sub>	Rise Time	—	—	90		
t <sub>d(off)</sub>	Turn-Off Delay Time	—	—	90		
t <sub>f</sub>	Fall Time	—	—	90		
LD	Internal Drain Inductance	—	TBD	—	nH	<p>Measured from the drain lead, 6mm (0.25 in.) from package to center of die.</p> <p>Measured from the source lead, 6mm (0.25 in.) from package to source bonding pad.</p>  <p>Modified MOSFET symbol showing the internal inductances.</p>
LS	Internal Source Inductance	—	TBD	—		
C <sub>iss</sub>	Input Capacitance	—	1100	—	pF	V <sub>GS</sub> = 0V, V <sub>DS</sub> = -25V f = 1.0 MHz
C <sub>oss</sub>	Output Capacitance	—	310	—		
C <sub>rss</sub>	Reverse Transfer Capacitance	—	55	—		

## Source-Drain Diode Ratings and Characteristics

	Parameter	Min.	Typ.	Max.	Units	Test Conditions
I <sub>S</sub>	Continuous Source Current (Body Diode)	—	—	-6.5	A	Modified MOSFET symbol showing the integral Reverse p-n junction rectifier. 
I <sub>SM</sub>	Pulse Source Current ① (Body Diode)	—	—	-26		
V <sub>SD</sub>	Diode Forward Voltage	—	—	-5.0	V	T <sub>j</sub> = 25°C, I <sub>S</sub> = -6.5A, V <sub>GS</sub> = 0V ④
t <sub>rr</sub>	Reverse Recovery Time	—	—	400	ns	T <sub>j</sub> = 25°C, I <sub>F</sub> = -6.5A, di/dt ≤ -100 A/μs V <sub>DD</sub> ≤ -50V ④
Q <sub>RR</sub>	Reverse Recovery Charge	—	—	3.0	μC	
t <sub>on</sub>	Forward Turn-On Time	Intrinsic turn-on time is negligible. Turn-on speed is substantially controlled by L <sub>S</sub> + L <sub>D</sub> .				

## Thermal Resistance

	Parameter	Min.	Typ.	Max.	Units	Test Conditions
R <sub>thJC</sub>	Junction-to-Case	—	—	1.67	K/W ⑤	Soldered to a copper-clad PC board
R <sub>thJ-PCB</sub>	Junction-to-PC board	—	TBD	—		

**Radiation Performance of P-Channel Rad Hard HEXFETs**

International Rectifier Radiation Hardened HEXFETs are tested to verify their hardness capability. The hardness assurance program at International Rectifier uses two radiation environments.

Every manufacturing lot is tested in a low dose rate (total dose) environment per MIL-STD-750, test method 1019. International Rectifier has imposed a standard gate voltage of -12 volts per note 6 and a  $V_{DSS}$  bias condition equal to 80% of the device rated voltage per note 7. Pre- and post-radiation limits of the devices irradiated to  $1 \times 10^5$  Rads (Si) are identical and are presented in Table 1. The values in Table 1 will be met for either of the two low dose rate test circuits that are used.

Both pre- and post-radiation performance are tested and specified using the same drive circuitry and test conditions in order to provide a direct comparison. It should be noted that at a radiation level of  $1 \times 10^5$  Rads (Si), no change in limits are specified in DC parameters.

High dose rate testing may be done on a special request basis, using a dose rate up to  $1 \times 10^{12}$  Rads (Si)/Sec.

International Rectifier radiation hardened P-Channel HEXFETs are considered to be neutron-tolerant, as stated in MIL-PRF-19500 Group D. International Rectifier P-Channel radiation hardened HEXFETs have been characterized in heavy ion Single Event Effects environment the results are shown in Table 3.

**Table 1. Low Dose Rate** ⑥ ⑦

Parameter		IRHN9230		Units	Test Conditions ⑩
		100K Rads (Si) min.	max.		
$BV_{DSS}$	Drain-to-Source Breakdown Voltage	-200	—	V	$V_{GS} = 0V, I_D = -1.0 \text{ mA}$
$V_{GS(th)}$	Gate Threshold Voltage④	-2.0	-4.0		$V_{GS} = V_{DS}, I_D = -1.0 \text{ mA}$
$I_{GSS}$	Gate-to-Source Leakage Forward	—	-100	nA	$V_{GS} = -20V$
$I_{GSS}$	Gate-to-Source Leakage Reverse	—	100		$V_{GS} = 20V$
$I_{DSS}$	Zero Gate Voltage Drain Current	—	-25	$\mu A$	$V_{DS} = 0.8 \times \text{Max Rating}, V_{GS} = 0V$
$R_{DS(on)1}$	Static Drain-to-Source④ On-State Resistance One	—	0.8	$\Omega$	$V_{GS} = -12V, I_D = -4.0A$
$V_{SD}$	Diode Forward Voltage④	—	-5.0	V	$T_C = 25^\circ C, I_S = -6.5A, V_{GS} = 0V$

**Table 2. High Dose Rate** ⑧

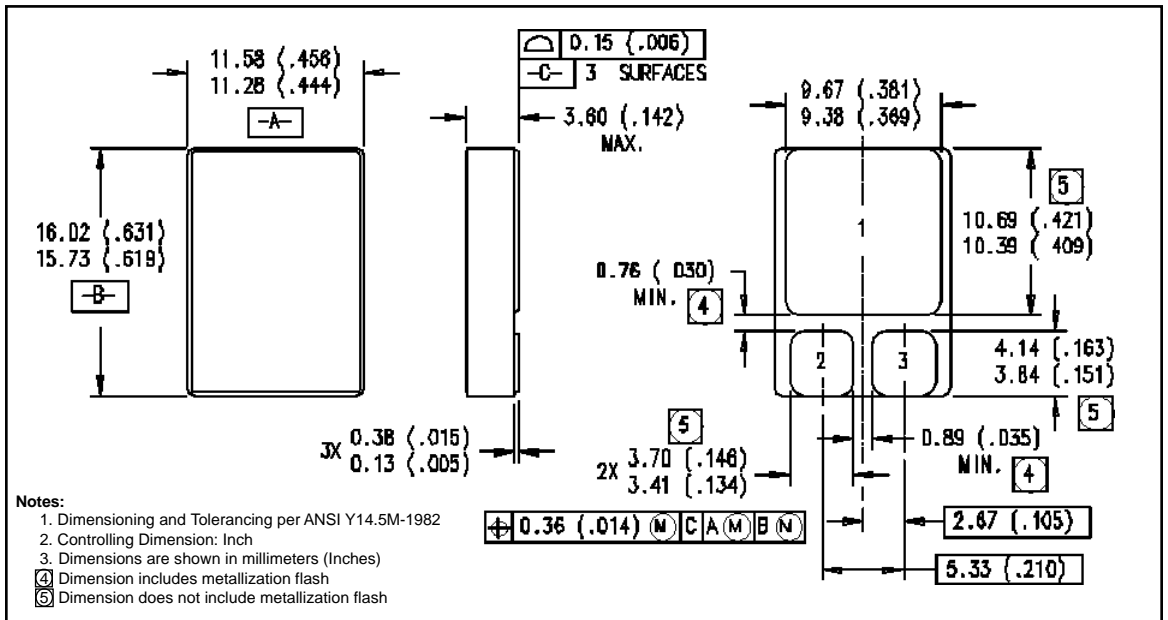
Parameter	10 <sup>11</sup> Rads (Si)/sec			10 <sup>12</sup> Rads (Si)/sec			Units	Test Conditions
	Min.	Typ	Max.	Min.	Typ.	Max.		
$V_{DSS}$	—	—	-160	—	—	-160	V	Applied drain-to-source voltage during gamma-dot
$I_{PP}$	—	-60	—	—	-60	—	A	Peak radiation induced photo-current
di/dt	—	-800	—	—	-160	—	A/ $\mu$ sec	Rate of rise of photo-current
$L_1$	27	—	—	0.5	—	—	$\mu H$	Circuit inductance required to limit di/dt

**Table 3. Single Event Effects** ⑨

Parameter	Typ.	Units	Ion	LET (Si) (MeV/mg/cm <sup>2</sup> )	Fluence (ions/cm <sup>2</sup> )	Range ( $\mu m$ )	$V_{DS}$ Bias (V)	$V_{GS}$ Bias (V)
$BV_{DSS}$	-200	V	Ni	28	$1 \times 10^6$	~41	-200	+5

- ① Repetitive Rating; Pulse width limited by maximum junction temperature. Refer to current HEXFET reliability report.
- ② @  $V_{DD} = -50V$ , Starting  $T_J = 25^\circ C$ ,  $EAS = [0.5 * L * (I_L)^2 * [BV_{DSS}/(BV_{DSS}-V_{DD})]]$   
 $25 \leq R_G \leq 200\Omega$ ,  $I_L = -6.5A$ ,  $V_{GS} = -12V$
- ③  $I_{SD} \leq -6.5A$ ,  $di/dt \leq -140 A/\mu s$ ,  $V_{DD} \leq BV_{DSS}$ ,  $T_J \leq 150^\circ C$
- ④ Pulse width  $\leq 300 \mu s$ ; Duty Cycle  $\leq 2\%$
- ⑤  $K/W = ^\circ C/W$   
 $W/K = W/^\circ C$
- ⑥ **Total Dose Irradiation with  $V_{GS}$  Bias.**  
 $-12$  volt  $V_{GS}$  applied and  $V_{DS} = 0$  during irradiation per MIL-STD-750, method 1019.
- ⑦ **Total Dose Irradiation with  $V_{DS}$  Bias.**  
 $V_{DS} = 0.8$  rated  $BV_{DSS}$  (pre-radiation) applied and  $V_{GS} = 0$  during irradiation per MIL-STD-750, method 1019.
- ⑧ This test is performed using a flash x-ray source operated in the e-beam mode (energy  $\sim 2.5$  MeV), 30 nsec pulse.
- ⑨ Process characterized by independent laboratory.
- ⑩ All Pre-Radiation and Post-Radiation test conditions are identical to facilitate direct comparison for circuit applications.

**Case Outline and Dimensions — SMD-1**



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Data and specifications subject to change without notice. 6/96